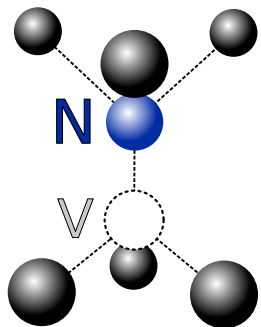
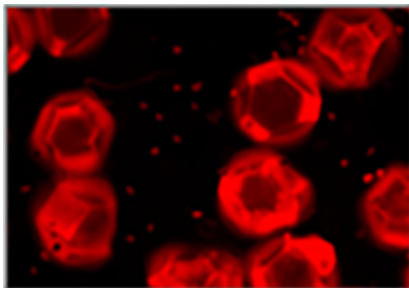


NV center



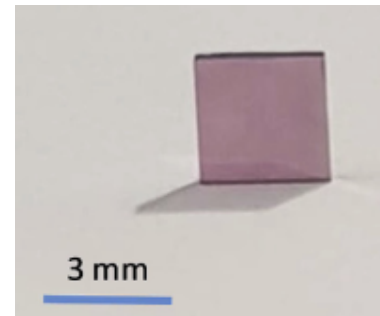
High Pressure High Temperature  
(HPHT)



Adamas 15/150  $\mu\text{m}$

$[\text{NV}] \approx 3 \text{ ppm}$

Chemical Vapour Deposition  
(CVD)



IRCP-LSPM

$[\text{NV}] \approx 4.5 \text{ ppm}$

Tallaire, A., et al (2020). Carbon, 170, 421-429.

Edmonds, A. M. et al (2021). Materials for Quantum Technology, 1(2), 025001.